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Contents

v	<i>Authors</i>
vii	<i>Conference Committee</i>

MATERIALS FOR MICRO-OPTICS

- 9888 05 **Cost-effective and large-area process for the functionalization and surface microstructuring using photo-patternable TiO₂ sol-gel process and colloidal photolithography** [9888-4]
- 9888 07 **System analysis of wavelength beam combining of high-power diode lasers for photoacoustic endoscopy** [9888-6]
- 9888 08 **Direct sub-micron microstructuring on cylinder using TiO₂ sol-gel process and radial phase mask based lithography** [9888-7]

OPTICAL MEMS COMPONENTS

- 9888 0A **Comparison of fabrication methods for microstructured deep UV multimode waveguides based on fused silica** [9888-8]
- 9888 0B **Dual fiber optical trapping in a polymer-based microfluidic chip** [9888-9]
- 9888 0C **Fabrication process of Si microlenses for OCT systems** [9888-10]
- 9888 0D **A highly miniaturized NDIR methane sensor** [9888-11]
- 9888 0E **Proof-of-concept demonstration of free-form optics enhanced confocal Raman spectroscopy in combination with optofluidic lab-on-chip** [9888-12]

JOINT SESSION: POLYMER AND PRINTABLE MICRO-OPTICS I

- 9888 0F **Temperature characterization of integrated optical all-polymer Mach-Zehnder interferometers** [9888-13]
- 9888 0G **Ink-jet printing of host-guest systems based on acrylates with fluorescent dopants** [9888-14]

JOINT SESSION: POLYMER AND PRINTABLE MICRO-OPTICS II

- 9888 0H **Large area patterning using interference and nanoimprint lithography (Invited Paper)** [9888-16]
- 9888 0I **Optical temperature sensing on flexible polymer foils** [9888-17]

PROTOTYPING AND FABRICATION

- 9888 OK **Plasma treatment of fiber facets for increased (de)mating endurance in physical contact fiber connectors** [9888-19]
- 9888 OM **Replication of self-centering optical fiber alignment structures using hot embossing** [9888-21]
- 9888 OO **Asymmetric 2D spatial beam filtering by photonic crystals** [9888-23]

POSTER SESSION

- 9888 OP **Fabrication and evaluation of reflective wave plate with subwavelength grating structure** [9888-24]
- 9888 OQ **Development and characterization of high refractive index and high scattering acrylate polymer layers** [9888-25]
- 9888 OR **Design and fabrication of ripple-free CMOS-compatible stacked membranes for airgap optical filters for UV-visible spectrum** [9888-26]
- 9888 OS **Assembly of optical transceivers for board-level optical interconnects** [9888-27]
- 9888 OT **Wafer-level fabrication of arrays of glass lens doublets** [9888-28]
- 9888 OU **Precision glass molding of high-resolution diffractive optical elements** [9888-29]

Authors

Numbers in the index correspond to the last two digits of the six-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first four digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Albero, Jorge, 0T
Ayerden, N. Pelin, 0D
Bargiel, Sylwester, 0T
Barié, Nicole, 0M
Beri, Stefano, 0K, 0M
Berthod, L., 05, 08
Bläsi, B., 0H
Bock, Karlheinz, 0S
Bollgruen, Patrick, 0G
Callewaert, Manly, 0B
Carpintero, Guillermo, 07
de Coster, Diane, 0B, 0E
de Graaf, Ger, 0D, 0R
De Malsche, Wim, 0B
De Witte, Martijn, 0K
Dellea, O., 05
Dukwen, Julia, 0U
Ebraert, Evert, 0M
Eiselt, Thomas, 0Q
Elmlinger, Philipp, 0A
Enoksson, Peter, 0D
Froehly, Luc, 0T
Gadonas, R., 0O
Gaiffe, Olivier, 0T
Gailevicius, D., 0O
Gaizauskas, E., 0O
Gallego, Daniel C., 07
Gauthier-Manuel, Ludovic, 0T
Gawali, Sandeep Babu, 07
Ghaderi, Mohammadamir, 0R
Gleissner, Uwe, 0F, 0G, 0I, 0Q
Gomard, Guillaume, 0Q
Gorecki, Christophe, 0T
Guttman, Markus, 0M
Hanemann, Thomas, 0G, 0Q
Hauser, H., 0H
Hermerschmidt, Andreas, 0U
Herzig, Hans Peter, 0U
Hofmann, Meike, 0F, 0I
Höhn, O., 0H
Jourlin, Y., 05, 08
Jovic, A., 0C
Kaiser, Myriam, 0A
Kneissl, Michael, 0A
Kolew, Alexander, 0M
Korvink, Jan, 0G
Krauter, Johann, 0T
Kroyer, T., 0H
Kübler, V., 0H
Lamela, Horacio, 07
Langenecker, Alexa, 0F
Langlet, M., 05, 08
Laukkanen, J., 08
Leggio, Luca, 07
Lemmer, Uli, 0Q
Liu, Qing, 0E
Loterie, Damien, 0E
Lullin, Justine, 0T
Mager, Dario, 0G
Maigyte, L., 0O
Margallo, E., 0C
Megrin, Christof, 0G
Missinne, Jeroen, 0E
Nieweglowski, Krzysztof, 0S
Osiński, Marek, 07
Osten, Wolfgang, 0T
Ottevaere, Heidi, 0B, 0E
Pandraud, G., 0C
Parriaux, O., 08
Passilly, Nicolas, 0T
Peckus, M., 0O
Perrin, Stéphane, 0T
Plöger, Sven, 0U
Prater, Karin, 0U
Preinfalk, Jan, 0Q
Priester, Roman, 0A
Purlys, V., 0O
Radulescu, Radu, 0K
Reynaud, S., 05, 08
Rodriguez, Sergio, 07
Rubio, J. L., 0C
Sacher, Joachim, 07
Sánchez, Miguel, 07
Sarro, P. M., 0C
Scharf, Toralf, 0U
Schmid, Marc, 0A
Schmidt, Thomas, 0I
Schneider, Marc, 0M
Schreivogel, Martin, 0A
Shavdina, O., 05
Shermann, Stanislav, 0F, 0I
Sonström, Patrick, 0A
Staliunas, K., 0O
Thienpont, Hugo, 0B, 0E, 0K, 0M
Tucher, N., 0H
Van Erps, Jürgen, 0B, 0E, 0K, 0M
Veillas, C., 05, 08
Verrier, I., 05, 08

Vervaeke, Michael, OB, OE
Vocanson, F., 05, 08
Voss, Kevin, OK
Wang, Ziyu, OF
Watté, Jan, OK, OM
Wellens, Ch., OH
Wissmann, Markus, OM
Wolffenbuttel, Reinoud F., OD, OR
Worgull, Matthias, OM
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- 1 Modelling and Design
Hans Zappe, Universität Freiburg (Germany)

- 2 Materials for Micro-Optics
Yanfen Xiao, Universität Freiburg (Germany)

- 3 Optical MEMS Components
Geert Van Steenberge, Universiteit Gent (Belgium)

- Joint Session: Polymer and Printable Micro-Optics I
Volker van Elsbergen, Philips Technologie GmbH (Germany)

- Joint Session: Polymer and Printable Micro-Optics II
Hans Zappe, Universität Freiburg (Germany)

- 4 Prototyping and Fabrication
Olivier Parriaux, Laboratoire Hubert Curien (France)